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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/608,776	06/30/2003	Kei Yamamoto	204552028900	8129
Barry E. Bretsc	7590 11/28/200 hneider	EXAMINER		
Morrison & Foo Suite 300		FORDE, DELMA ROSA		
1650 Tysons Bo	oulevard	ART UNIT	PAPER NUMBER	
McLean, VA 22	2102	2828		
			MAIL DATE	DELIVERY MODE
			11/28/2008	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)		
	10/608,776	YAMAMOTO ET AL.		
Office Action Summary	Examiner	Art Unit		
	DELMA R. FORDE	2828		
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet with	the correspondence address		
A SHORTENED STATUTORY PERIOD FOR REF WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory per - Failure to reply within the set or extended period for reply will, by sta Any reply received by the Office later than three months after the ma earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICA 1.136(a). In no event, however, may a reply iod will apply and will expire SIX (6) MONTH tute, cause the application to become ABAN	TION. be timely filed from the mailing date of this communication. DONED (35 U.S.C. § 133).		
Status				
Responsive to communication(s) filed on <u>03</u> This action is FINAL . 2b) ☑ T Since this application is in condition for allow closed in accordance with the practice under	his action is non-final. wance except for formal matters			
Disposition of Claims				
4) ☐ Claim(s) 1-22 is/are pending in the applicati 4a) Of the above claim(s) is/are withd 5) ☐ Claim(s) 9-22 is/are allowed. 6) ☐ Claim(s) 1-8 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and Application Papers 9) ☐ The specification is objected to by the Exam 10) ☐ The drawing(s) filed on is/are: a) ☐ a	drawn from consideration. d/or election requirement. iner.	the Examiner.		
Applicant may not request that any objection to t Replacement drawing sheet(s) including the corr 11) The oath or declaration is objected to by the	he drawing(s) be held in abeyance rection is required if the drawing(s)	. See 37 CFR 1.85(a). is objected to. See 37 CFR 1.121(d).		
Priority under 35 U.S.C. § 119				
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 				
Attachment(s) 1) ☑ Notice of References Cited (PTO-892) 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) ☑ Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 07/17/2008.	Paper No(s)/N	nmary (PTO-413) Iail Date mal Patent Application		

DETAILED ACTION

Appeal Brief

In view of the Appeal Brief filed on 07/03/2008, PROSECUTION IS HEREBY REOPENED. *A new ground of rejection is* set forth below.

To avoid abandonment of the application, appellant must exercise one of the following two options:

- (1) file a reply under 37 CFR 1.111 (if this Office action is non-final) or a reply under 37 CFR 1.113 (if this Office action is final); or,
- (2) initiate a new appeal by filing a notice of appeal under 37 CFR 41.31 followed by an appeal brief under 37 CFR 41.37. The previously paid notice of appeal fee and appeal brief fee can be applied to the new appeal. If, however, the appeal fees set forth in 37 CFR 41.20 have been increased since they were previously paid, then appellant must pay the difference between the increased fees and the amount previously paid.

A Supervisory Patent Examiner (SPE) has approved of reopening prosecution by signing below:

/Minsun Harvey/

Supervisory Patent Examiner, Art Unit 2828.

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The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that

form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United

States.

Claims 1 – 8 are rejected under 35 U.S.C. 102(b) as being anticipated by Andrea

Oster, et al. "Gain spectra measurement of strained and strain-compensated InGaAsP-

AlGaAs Laser structure for λ ≈ 800 nm."

Regarding claims 1, 5, 8 and 23, Oster (Examiners includes Tables I and II, see

next page) discloses semiconductor laser device having an oscillation wavelength of

larger than 760nm and smaller than 800nm (see abstract and page 635 Table II and

first paragraph of "BA Lasers") in which at least a lower clad layer (see Table I on page

632) a lower guide layer (see Table I on page 632, the reference call "waveguide"), an

active region (see Table I on page 632) and upper guide layer (see Table I on page

632and an upper clad layer (see Table I on page 632) are supported by GaAs substrate

(see Table I on page 632), the active region having a quantum well (see Table I on

page 632) structure in which one or more well layers and barrier layers (see Table I on

page 632) are stacked, wherein one or more well layers are formed of InGaAsP (see

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Table I on page 632) and said barrier layer are formed of, GaAsP (see Table I on page 632) and said upper and/or lower guide layer is formed of $Al_zGa_{1-z}As$ (0.20<z<1) (see Table I on page 632).

TABLE I
LAYER SEQUENCE OF LASER STRUCTURES UNDER INVESTIGATION

layer		and specifical	sbickness (nm)
contact		p-GaAs	
cladding		p-Al _{co} Ga _{co} As	1800
waveguide		p-Al _{ses} Ga _{sas} As Al _{ses} Ga _{sas} As+ Al _{ses} Ga _{sas} As	500 10
	Á	InnaoCanasAsuraPaas	18
active	33	In _{eza} Cas _{tra} As _{tra} Po ₄	13
region	С	Ino.24Ga022AS622P0.24	5
	D	GaAs _{arr} P _{ars} Is _{sra} Gs _{arr} As _{arr} P _{ars} GaAsarrPars	§ 5
waveguide		Al _{0.87} Ga _{0.98} As> Al _{0.67} Ga _{0.98} As B-Al _{0.96} Ga _{0.98} As	10 500
cksdding		n-Al _{ex} Ca _{6,X} As	2000
buffer		n-GaAs	
substrate		a-GsAs	

TABLE II CHARACTERISTIC DATA FROM PULSED BA LAGER MEASUREMENT (PULSE LENGTH: 500 ms., DUTY CYCLE: 1:400)

Sample	Α	В	C	a		
60w (%)	0.1	0.6	1,0	0.1		
_{Бв} (%)			_r	-1.0		
λ (tan)	796	808	791	797		
sh (%)	75	79	77	92		
$\alpha_k(cm^3)$	»l	*1	ક્ર	#3}		
j _a (A cm²)	200	128	150	137		
$\Gamma \cdot G_0$	18.5	14	19	18		

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Regarding claims 2 and 5, Oster discloses a value of z representing a mole

fraction of AI in the group III element of said upper and/or lower guide layer is larger

than 0.25 (see Table I on page 632), a value of z, where a value of z represents a mole

fraction of A1 in the group-III elements of said upper and/or lower guide layer, of at least

a portion in contact with a barrier layer of said upper and/or lower guide layer is smaller

than 0.4. (See Table I on page 632).

Regarding claims 3, and 4, Oster discloses a upper and lower cladding (see

Table I on page 632) contain AI, and a value of z, wherein a value of z represent a mole

fraction of AI in the group-III elements of said upper and/or lower guide layer, is smaller

than a value of an Al mole fraction of said upper and lower clad layer and the value of z

varies stepwise or continuously and is such a fashion as to increase with increasing

nearness to said upper and lower clad layers (see Table I on page 632).

Regarding claims 6 – 8, Oster discloses a one or more well layers and barrier

layer have a compressive or tensile strain (abstract and see page 623 third paragraph

of "II. Experimental") and the semiconductor laser device is used as a light-emitting

device (page 632, II. Experimental: III. "Gain measurement method", third paragraph).

Allowable Subject Matter

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Claims 9 – 22 are allowed.

The following is an examiner's statement of reasons for allowance: Claim 9 recites a semiconductor laser structure including the specific structure limitation of barrier layer are formed of an $In_{1-x}Ga_x$ $As_{1-y}P_y$ having a band gap energy larger than that of said well layers, and there hold relationship that 0 < x < 1; 0.02 < y < 0.75 and |(a2 - a1)/a1| * 100 0.65, where a1 is lattice constant of said one or more well layers, and a2 is lattice constant of said barrier layers, which is neither anticipated or disclosed nor suggested in any piece of available prior art, which is neither anticipated nor obvious over the prior art of record.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Response to Arguments

Applicant's arguments with respect to claims 1 - 22 have been considered but are most in view of the new ground(s) of rejection.

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Conclusion

Any inquiry concerning this communication or earlier communications from the

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examiner should be directed to DELMA R. FORDE whose telephone number is

(571)272-1940. The examiner can normally be reached on M-T.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, MinSun O. Harvey can be reached on 571-272-1835. The fax phone

number for the organization where this application or proceeding is assigned is 571-

273-8300.

Information regarding the status of an application may be obtained from the

Patent Application Information Retrieval (PAIR) system. Status information for

published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only.

For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a

USPTO Customer Service Representative or access to the automated information

system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/DELMA R. FORDE/

Examiner, Art Unit 2828

/Minsun Harvey/

Supervisory Patent Examiner, Art Unit 2828